

**FORMATION OF PROJECTIONS AND SPACERS AND RADIATION
SENSITIVE RESIN COMPOSITION FOR THE SAME**

Abstract of the disclosure:

A radiation sensitive resin composition which contains at least one alkali-soluble resin selected from the group consisting of a novolak resin having a weight average
5 molecular weigh in terms of polystyrene measured by gel permeation chromatography of 2,000 to 20,000 and a hydroxystyrene resin having a weight average molecular weight in terms of polystyrene measured by gel permeation chromatography of 10,000 to 100,000, a polyfunctional
10 monomer or a combination of a polyfunctional monomer and a monofunctional monomer and a photopolymerization initiator. The composition is used to form projections and spacers in a vertically aligned liquid crystal display device having an after-image erase time of 100 sec or less.